



Docket No.1539.1002RE/EMP/JGM

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Reissue Application of :
Tomowaki TAKAHASHI :
Serial No.: 09/659,375 ✓ : Group Art Unit: 2872
Filed: September 8, 2000 : Examiner: J. Henry
For: CATADIOPTIC PROJECTION SYSTEMS

AMENDMENT

Assistant Commissioner for Patents
Washington, D.C. 20231

Sir:

This is responsive to the Office Action mailed February 13, 2001, having a shortened period for response set to expire on May 14, 2001, May 13, 2001 being a Sunday.

The following amendment and remarks are respectfully submitted.

IN THE SPECIFICATION:

Please REPLACE the first full paragraph on page 9 with the following paragraph:

--The turning mirror M_2 directs the light from the illuminated region of the reticle R along the optical axis 310 which is an optical axis of the second imaging system B as well as of the single-pass lens group A_1 . The second imaging system B receives light from the turning mirror M_2 and re-images the intermediate image onto a corresponding region 331 on the wafer W. As will be apparent, the second embodiment differs from the first embodiment in that the

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Amend
J. Miller
4/21/01

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